

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

In re Patent Application of

Atty. Ref.: **4662-138**

**SHAHAB et al**

Conf. No.: **9555**

Serial No. **10/565,505**

Group: **1795**

Filed: **July 6, 2006**

Examiner: **Johnson**

For: **DISSOLUTION INHIBITORS IN PHOTORESIST COMPOSITIONS FOR  
MICROLITHOGRAPHY**

\* \* \* \* \*

July 15, 2008

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

**AMENDMENT AND RESPONSE TO RESTRICTION REQUIREMENT**

Sir:

The following comments and amendments are intended to be fully responsive to the Official Action dated June 18, 2008, which set a nominal response due date of July 18, 2008.

Pursuant to 37 CFR §1.121, each section of the subject Amendment (e.g., Claim Amendments, Specification Amendments, Drawing Amendments and Remarks) as may be appropriate to the issues raised in the Official Action to which this paper responds, begins on a separate page. Changes to the original text, claims and the like are shown by striking through language to be deleted and underlining of language to be added.